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Wavelet based spectral approach for solving surface coverage model in an electrochemical arsenic sensor - An operational matrix approach

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Abstract

Surface coverage parameter of an electrochemical sensor plays a vital role in enhancing the figure of merits of the sensor. Developing a theoretical model for the surface coverage will help to standardize the fabrication of working electrodes used in electrochemical sensors. In this background, a wavelet based spectral algorithm has been developed to model the surface coverage of an arsenic sensor. For the model, Michaelis-Menten constant of fluorine doped cadmium oxide (F-doped CdO) working electrode based arsenic sensor was used as the seed fount. Theoretical analysis for the estimation of surface coverage based on Michaelis-Menten constant with nonlinear reaction-diffusion equation is considered. In order to estimate the Michaelis-Menten constant and maximum current response, the measured current values are linearized with the help of Hanes-woolf plot. Using the Legendre wavelet spectral approach, the nonlinear reaction-diffusion equation is converted into a system of algebraic equations through operational

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